Quantum Hall Effect, Screening, and Layer-Polarized Insulating States in Twisted Bilayer Graphene

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We investigate electronic transport in dual-gated twisted-bilayer graphene. Despite the subnanometer proximity between the layers, we identify independent contributions to the magnetoresistance from the graphene Landau level spectrum of each layer. We demonstrate that the filling factor of each layer can be independently controlled via the dual gates, which we use to induce Landau level crossings between the layers. By analyzing the gate dependence of the Landau level crossings, we characterize the finite interlayer screening and extract the capacitance between the atomically spaced layers. At zero filling factor, we observe an insulating state at large displacement fields, which can be explained by the presence of counterpropagating edge states with interlayer coupling.

The bilayer two-dimensional electron gas (2DEG) consists of two closely spaced 2DEGs, where interlayer Coulomb interactions and tunneling effects can lead to new behaviors which are not present in the individual layers [1–3]. In these bilayers, an insulating spacer is necessary to separate the 2DEG layers. In the case of twisted-bilayer graphene, the layers can be stacked directly on top of each other, yet still retain a degree of independence. This is possible because of the carbon honeycomb lattice of graphene, which results in weak coupling between the layers [4], as well as a circular Fermi surface centered at nonzero $K$ vectors [5]. The latter is key, because a relative twist angle between the graphene bilayer lattices can cause the Fermi surfaces of the two layers to not overlap at low densities [Figs. 1(a) and 1(b)]. This preserves the linear Dirac dispersion in the twisted-bilayer graphene [6–12], but with twice the number of Dirac cones due to the two layers [6,9,12].

Here, we present magnetoresistance measurements of dual-gated twisted-bilayer graphene devices (twisted bilayers), which exhibit the quantum Hall effect (QHE) and magnetoresistance oscillations of two monolayer graphene (MLG) sheets conducting in parallel. As we vary the gate voltages, we observe interlayer Landau level crossings which allow us to quantify both the layer charge transfer, as well as the finite screening effects between the layers. This incomplete screening of the applied field, due to graphene’s small density of states and the close spacing between the layers, allows us to extract the interlayer capacitance. Lastly, at high magnetic fields we observe a pattern of insulating states centered at zero density which resemble those observed in $AB$-stacked bilayer graphene ($AB$-BLG) [13,14], but originate from layer-polarized edge modes.

Our twisted-bilayer devices are fabricated using a PMMA-transfer technique to sequentially stack two separate MLG sheets such that they overlap on top of a hexagonal boron nitride ($h$-BN) flake [15,16]. The bilayer region formed at the overlap is then contacted, and a top gate is fabricated with a $h$-BN flake as the dielectric insulator [17]. The final devices are measured in a He3 cryostat, with the temperature at 300 mK unless otherwise noted.

Using our devices’ dual gates we can independently control the total carrier density $n_{tot}$ of the twisted bilayer, as well as the displacement field $D$ applied normal to the
layers [Fig. 1(c)]. The total carrier density of the twisted bilayer is \( n_{\text{tot}} = (C_TV_{\text{TG}} + C_BV_{\text{BG}}) \), where \( C_T \) (B) is the capacitance per unit area to ground of the top (bottom) gate, \( V_{\text{BG}} \) is the potential difference between the top (bottom) gate and the graphene layer closest to it [17], and \( e \) is the elementary charge. The applied displacement field is \( D = (C_TV_{\text{TG}} - C_BV_{\text{BG}})/2 \), which induces charge and voltage differences between the layers.

We first compare our twisted-bilayer samples with \( AB\)-BLG by measuring the resistance of the charge neutrality point (CNP) as a function of \( D \). In \( AB\)-BLG, a displacement field breaks the bilayer’s inversion symmetry, which opens a band gap at the CNP [18–20]. This is not predicted to occur in twisted bilayers [6], and in our samples the CNP resistance decreases almost linearly as \( D \) increases [Fig. 1(d)]. This is a strong indication that our bilayers are not \( AB \) stacked. Instead, the effect of \( D \) at the CNP can be explained as doping the two layers with equal and opposite charge, reducing the resistance of each individual layer [17].

At high magnetic field \( B \), we measure a QHE which is distinctly different from that observed in MLG [21, 22] or \( AB\)-BLG [23]. At \( D = 0 \), we measure the Hall resistance \( R_{xy} \) as a function of total filling factor \( \nu_{\text{tot}} = n_{\text{tot}}h/eB \), where \( h \) is Planck’s constant [Fig. 2(b), black line]. We observe plateaus following the progression \( 1/R_{xy} = \nu(e^2/h) \), where \( \nu = 4, 12, 20 \). These steps of \( 8e^2/h \) between each plateau of \( 1/R_{xy} \) indicate the presence of eightfold degenerate Landau levels (LLs). This eightfold degeneracy follows from the usual spin (\( \uparrow, \downarrow \)) and valley (\( K, K' \)) degeneracies found in MLG [21, 22], with an additional twofold degeneracy which we ascribe to the layer degree of freedom (\( U, L \) for upper and lower layer, respectively) [Fig. 2(a)] [24].

This layer degeneracy at \( D = 0 \) was observed in three different samples, and can be seen up to high filling factors in the longitudinal resistance as well. Figure 2(f) shows longitudinal resistance measurements \( R_{\text{xx}}' \), where a smooth background has been subtracted to improve the contrast of magnetoresistance peaks [17]. When \( D = 0 \), peaks in \( R_{\text{xx}}' \) are separated by \( \Delta \nu_{\text{tot}} = 8 \), again indicating eightfold degenerate LLs, with this trend verified as far as \( \nu_{\text{tot}} = -72 \).

A property of the twisted bilayers is that the layer degeneracy can be easily broken by applying a

![FIG. 2 (color online). Quantum Hall effect, Landau level (LL) crossings, and screening in twisted bilayers. (a) Schematic of twisted-bilayer LL spectrum. LLs are eightfold degenerate (\( g = 8 \)) due to spin, valley, and layer degeneracy. Displacement field \( D \) breaks layer degeneracy (\( g = 4 \)). (b) \( 1/R_{xy} \) as a function of total filling factor \( \nu_{\text{tot}} \) at \( B = 9 \) T. At \( D = 0 \), steps in \( 1/R_{xy} \) of \( 8e^2/h \) are observed (black line); at \( D/e_0 = -145 \) mV/nm, new steps of \( 4e^2/h \) develop. (c) Diagram of interlayer screening. The applied field \( D \) is screened by charge imbalances \( \Delta n \) and by the interlayer dielectric constant \( \varepsilon_{\text{GG}} \). The total screened field \( E_{\text{tot}} \) induces an interlayer potential difference \( \Delta V \). (d) LL energy spectra of upper and lower graphene layers (red and blue lines, respectively) as a function of \( \nu_{\text{tot}} \). (e) Simulated density of states for twisted bilayer as a function of \( \nu_{\text{tot}} \) and \( \Delta V \). (f) Measured longitudinal resistance \( R_{\text{xx}}' \) with background subtracted, as a function of \( D \) and \( \nu_{\text{tot}} \) at \( B = 4 \) T. Peaks in \( R_{\text{xx}}' \) cross as a function of \( D \), indicating the crossing of LLs. Black dots are theoretical fits to the LL crossings, from which the interlayer capacitance is extracted.

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displacement field normal to the graphene layers, resulting in fourfold degenerate LLs, which we observe as new steps of $4e^2/h$ in $1/R_{xy}$ [Fig. 2(b), purple line]. These LL splittings are also seen clearly in $R_{xx}^{\text{GG}}$, where each peak in $R_{xx}^{\text{GG}}$ at $D = 0$ splits in two for $|D| > 0$ [Fig. 2(f)]. As $D$ is increased further, these peaks cross with their neighbors, indicating the crossing of LLs between the layers. To model the pattern of possible LL crossings, we consider independent MLG LL energy spectra in each layer with a potential difference $\Delta V$ between the upper and lower layer induced by $D$ [Fig. 2(d)]. The upper and lower layer LLs (red and blue lines, respectively), are degenerate at $\Delta V = 0$, and split in energy as $|\Delta V|$ increases, resulting in energy crossings when $-e\Delta V$ is equal to the energy spacing between two MLG LLs. This condition is satisfied when $-e\Delta V = \mathcal{E}_{\text{LL}}(N_U) - \mathcal{E}_{\text{LL}}(N_L)$, where $\mathcal{E}_{\text{LL}}(N) = \text{sgn}(N)\nu_F\sqrt{2\epsilon_ehB|\mathcal{N}|}$, $N_U$ and $N_L$ are the LL indices for the upper and lower layer, respectively, and $\nu_F$ is the MLG Fermi velocity [5]. This energy plot is the flling factor by modeling each LL by a Lorentzian density of states with disorder broadening [Fig. 2(e)]. The resulting plot of two intersecting LL spectra qualitatively reproduces all the peaks in $R_{xx}^{\text{GG}}$ presented in Fig. 2(f).

The relationship between the applied $D$ and the induced $\Delta V$ at a crossing is determined by the interlayer screening properties of the twisted bilayer, as $D$ will be screened both by free charges and the interlayer dielectric environment [Fig. 2(c)]. The total screened electric field $E_{\text{tot}}$ between the two graphene sheets with spacing $d_{\text{GG}}$ results in the potential difference $-\Delta V = E_{\text{tot}} \cdot d_{\text{GG}}$. The relation then is

$$-\Delta V = \left( D - \frac{e\Delta n}{2} \right) \frac{d_{\text{GG}}}{\epsilon_{\text{GG}}} = \left( D - \epsilon_0 E_S \right) \frac{1}{C_{\text{GG}}},$$

where $E_S$ is the screening field due to the layer density imbalance $\Delta n$, $\epsilon_{\text{GG}}$ is the interlayer dielectric constant, and $C_{\text{GG}} = \epsilon_{\text{GG}}/d_{\text{GG}}$ is the interlayer capacitance per unit area.

For a high density of states material, $\Delta V$ would be effectively zero and the charge imbalance $\Delta n$ would completely screen $D$, independent of the interlayer capacitance $C_{\text{GG}}$. Graphene though, has a small density of states, and a correspondingly small quantum capacitance which is comparable to the interlayer capacitance of the closely spaced graphene sheets. This leads to an incomplete charge screening of $D$ and a dependence of $\Delta n$ on $C_{\text{GG}}$ which we can measure. When the Fermi energy lies at a LL crossing with LL indices $N_U$ and $N_L$, we can determine both $\Delta V$ and $\Delta n [\Delta n = (N_U - N_L)4eB/h]$ and use Eq. (1) to compute the $D$ at which a crossing should be observed. We repeat this process for each crossing, and fit it to our data to extract $C_{\text{GG}}$. The computed crossings are overlaid as black circles on Fig. 2(f), resulting in good agreement when $C_{\text{GG}} = 6.8 \text{ mF/cm}^2$ (estimated error $\pm 1.0 \text{ mF/cm}^2$). A similar analysis was repeated on two other samples with LL crossings, both resulting in an extracted capacitance of $C_{\text{GG}} = 7.5 \pm 1.0 \text{ mF/cm}^2$. For comparison, the capacitance of two parallel plates separated by 0.34 nm of vacuum would be 2.6 $\mu$F/cm², which is less than half of our extracted capacitances (atomic force microscopy measurements indicate an interlayer step height that varies from 0.34 to 0.41 nm across our samples). Given that the interlayer distances are only somewhat larger than the spatial extent of the graphene $p_z$ orbitals [25], it seems likely that both the finite thickness of the graphene layer, and its polarizability [26], could increase the interlayer capacitance. A similar magnitude of screening also occurs in $AB$-BLG [27,28]. Another possible effect is Fermi velocity reduction, which has been demonstrated to occur in twisted bilayers at small twist angles [6,11,12,29]. In this case, since we assume $\nu_F$ to be the same as in isolated MLG, the interlayer capacitance could be even larger than we estimate and our extracted capacitance $C_{\text{GG}}$ sets a lower bound on this quantity.

We now turn to the $r_{\text{tot}} = 0$ region, where we see evidence of coupling between edge states in the two layers. At high $B$ field and $r_{\text{tot}} = 0$, the longitudinal resistivity $\rho_{xx}$ has two insulating regions: one at $D = 0$ and one at high $D$ [Fig. 3(a)]. Both insulating states have high resistivities ($> 100 \text{k} \Omega$) with a nonmetallic temperature dependence [Fig. 3(b)]. A similar pattern of insulating states has been observed in $AB$-BLG [13,14], but the mechanism for such states must be different in the twisted bilayers. In $AB$-BLG, high $D$ opens a band gap independent of $B$. Such an effect does not occur in the twisted bilayers [Fig. 1(d)] [6], and as seen in Fig. 3(c), the high $D$ insulating state disappears at low $B$ field.

This high $D$ insulating state can be explained by the coupling of counterpropagating edge states, which can coexist on the same edge of the twisted-bilayer sample when $r_{\text{tot}} = 0$. These crossings occur when $|D| > 0$, because the zeroth LL in graphene is made up of opposite chirality states with energy that diverges in opposite directions at the edge of the sample [Fig. 3(d)]. When the zeroth LL of the twisted bilayer is split in energy by $D$, the electronlike edge states in one layer (blue line) will cross the holelike edge states in the other (red line), resulting in counterpropagating, layer-polarized edge modes. A similar scenario has been previously considered for spin splitting in the zeroth LL in graphene, leading to spin currents [30]. In the case of twisted bilayer though, there should be a displacement-induced layer splitting of the zeroth LL, with associated “layer” current. Because the states counterpropagate along the same edge though, a backscattering channel is available by tunneling into the other layer. Such a process could lead to 1d localization [31], or an insulating gap due to an avoided crossing of the edge states [Fig. 3(d), dotted lines], both of which could explain the insulating behavior we observe.

The high $D$ insulating state at $r_{\text{tot}} = 0$ is separated by a low resistivity region from another insulating state at...
$D = 0$. The development of an insulating state at zero filling factor has been observed in MLG \[32\] and BLG \[13,33\], and is attributed to electron-electron interaction effects which break the degeneracy of the zeroth Landau level and open a gap at zero density. Given the presence of the low resistivity transition region between the two insulating states, it is unlikely then that both the high $D$ and $D = 0$ regions are layer-polarized states, since that would imply a continuous transition from one state to the other. The $D = 0$ state then could simply be both MLG sheets within some broken-symmetry state that does not involve the layer degree of freedom \[34\]. As $D$ increases, the layer-polarized state eventually becomes more energetically favorable, leading to the transition to the high $D$ insulating state.

These $\nu_{\text{tot}} = 0$ states indicate that layer interactions in the twisted-bilayer graphene can lead to new behaviors which cannot be explained by completely independent monolayer graphene sheets conducting in parallel. In principle, this interlayer coupling is tunable by varying the distance between the graphene layers, altering the twist angle, as well as by threading magnetic flux parallel to the layers.

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